L Number	Hits	Search Text	DB	Time stamp
10	79354	mosfet (metal near oxide near semiconductor near field-effect near transistor) (metal near oxide near semiconductor near field-effect near transistor) (mos with fet)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/01 12:33
11	1131388	trench$2 recess$2 trough$2	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/01 12:34
12	36515	body adj2 (region area)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/01 12:34
13	54383	epitaxial near2 (layer film)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/01 12:35
17	57149	(polycrystal$4 poly-crystal$4) with silicon	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/01 12:45
18	306	(mosfet (metal near oxide near semiconductor near field-effect near transistor) (metal near oxide near semiconductor near field-effect near transistor) (mos with fet)) and (trench$2 recess$2 trough$2) and (body adj2 (region area)) and (epitaxial near2 (layer film)) and ((polycrystal$4 poly-crystal$4) with silicon)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/01 12:45

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